

Exercise 3: A First Layout

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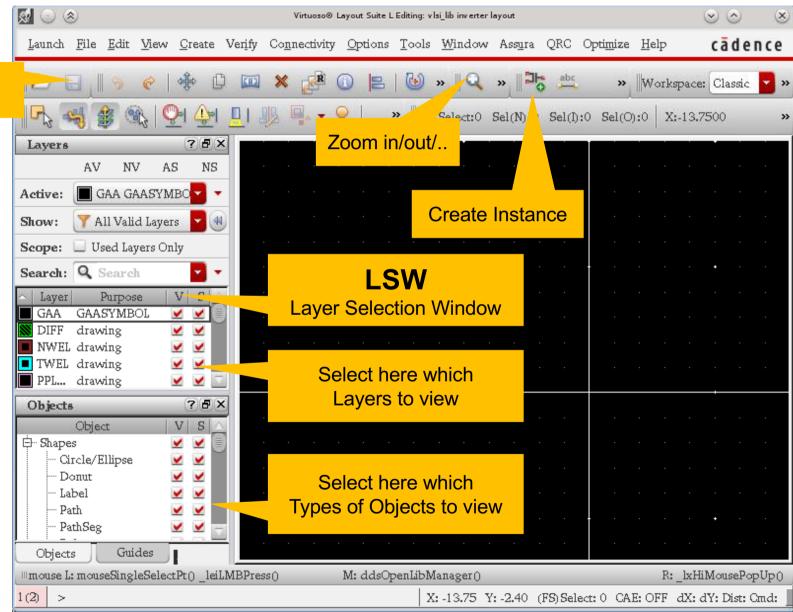
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The (Layout) Editor Window

CHECK and save

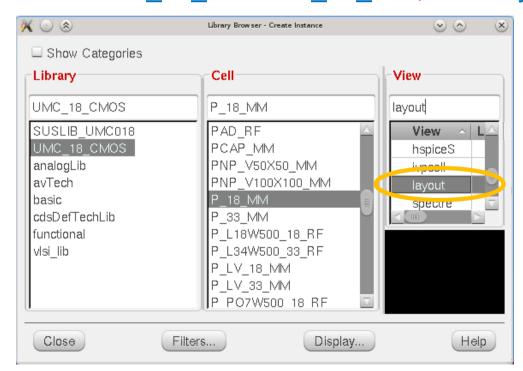






Adding a Transistor

- To add a component ('instance') to a layout:
 - Press the 'Create Instance' button or
 - select Create → Instance or
 - press 'i'
- Browse to the UMC_18_CMOS library
- Choose N_18_MM or P_18_MM, view layout

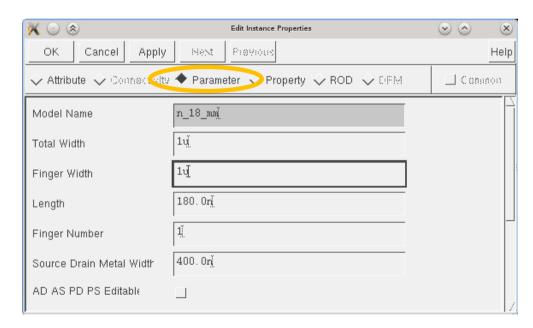






Changing Component Parameters

- To change *parameters* of an instance
 - Press the 'Edit Properties' button
 - select Create → Properties → Object or
 - press 'q' or
 - use the Property Editor Panel
- Chose the 'Parameter' tab



Observe how the layout of the part changes!





Intermezzo: Executing Commands

Two possibilities for most commands:

1. Execute command once:

- Select objects(s)
- Press command key
- Execute command (once)

2. Multiple execution:

- Press command key → switch to command mode (new cursor)
- Select objects to execute commands on them
- Press ESC = escape to end

• Example:

Select – delete delete one instance

• Delete – click – click – escape delete multiple





Changing User Preferences

- You can change the behaviour somewhat under CIW → Options → User Preferences
 - 'InFix' can be selected so that commands take action immediately, without extra mouse-click







Intermezzo: Getting more Command Options

- In general, pressing F3 while executing a command opens a window with more options.
 - rotate, flip
 - allowed routing angles
 - colors
 - •
- Sometimes need to press F3 twice





Moving an Instance

Select the instance with the mouse

leftclick to select individual instances

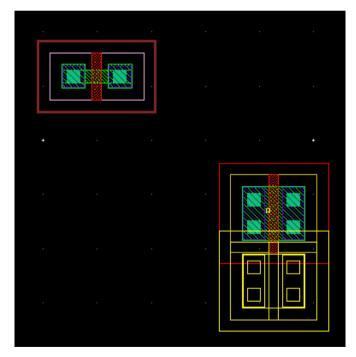
shift – leftclick to add instances to selection

ctrl – leftclick to remove instances from selection

drag rectangle select instances in area

To move

- Press 'Move' button or
- select Edit → Move or
- press 'm'
- Alternative:
 - First press 'm'
 - select move drop, …ESC
- Alternative:
 - click drag drop
- For options (snap mode, rotate, flip,..): F3







Setting User Mode Details

- By pressing 'g', the 'gravity' mode can be toggled. With gravity on, the cursor 'snaps' to 'interesting' locations.
 - You see the new gravity state in the CIW
 - For now, keep gravity off
- Important: F4 () toggles between
 - full select a shape is always completely selected
 - Partial select can select parts of a shape

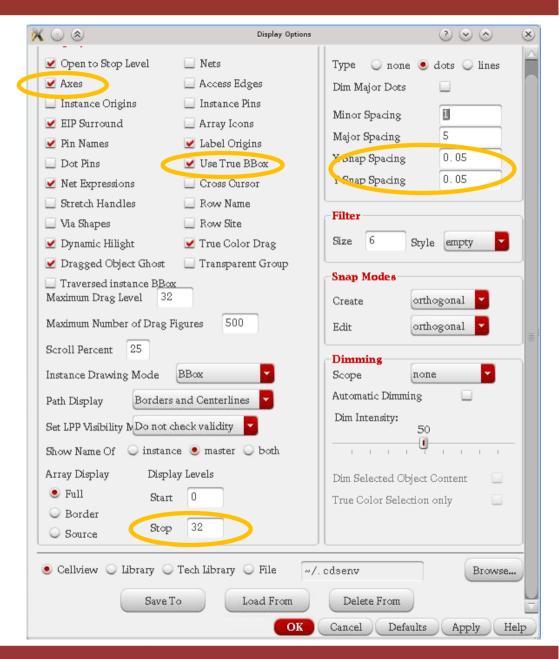
- The Origin can be moved via Edit → Advanced → Move Origin (+ click with new position of origin)
 - This is a dangerous command if you have already used the cell in other places: The cell will shift everywhere!





The Display Options Window

- Pressing 'e' brings up the Display Options Window
- It allows to set many things:
 - Axis on off
 - Dot Grid
 - SNAP GRID
 - Display Levels
 - •
- Switch Display Levels with
 - Shift-F or Ctrl-F
- You can save the settings to the cell

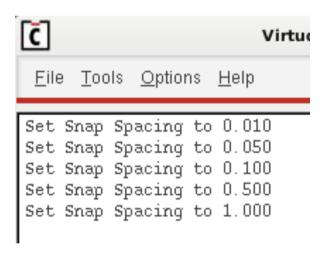






Additional Bind Keys for SNAP - Grid

- Changing the grid to the largest reasonable value is useful
- We have therefore created some extra short cuts to do this:
 - Keys 1, 2, 3, ... change the grid to increasingly coarse values
 - The value is displayed in the CIW:



You will learn how these keys are defined in the SKILL part



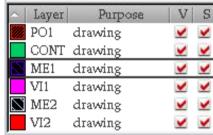


Adding Shapes

Before drawing a shape, select the layer in the Layer

Selection Window (LSW)

Start with Metal 1 = ME1



There are 3 different shape types

Rectangles Create → Shape → Rectangle or 'r'

Polygons Create → Shape → Polygon or 'Shift-P'

(double click to finish)

Paths Create → Shape → Path or 'p'

(double click to finish)

■ Paths have a width which can be changed by F3.



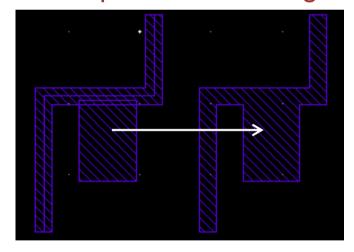


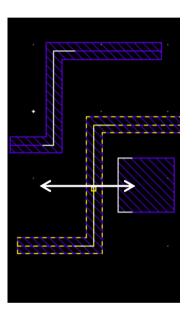
Modifying Shapes

- When partial selection is enabled (F4), a part of a shape can be selected and stretched or deleted
- Multiple segments can be selected
 - This is very powerful in Virtuoso!!

Several selected shapes can be merged

with 'Shift-M'





- Shapes can be chopped (cut) with 'Shift-C' (+ cut shape)
- Shapes can be converted to Polygons with Edit → Convert
 → to Polygon





Flatten

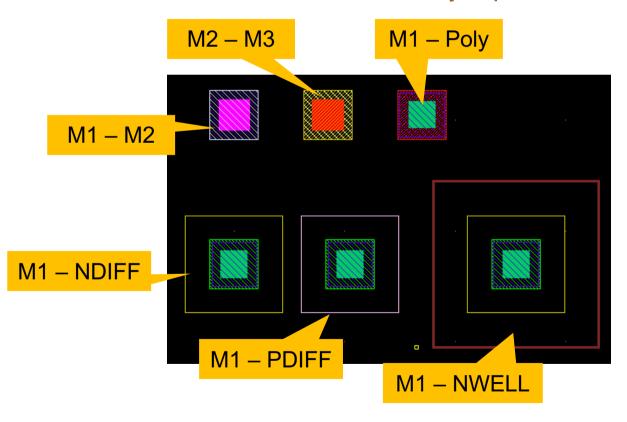
- All objects in an instance can be moved to the active cell view using the Flatten command.
 - The instance does not exist any more after this command, it is replaced by its content
- In fact, everything is 'pulled up' by one level in the hierarchy
- More than one level can be flattened at once
- When PCELLs are flattened, there are often several shapes on one layer. These can be MERGEd.
 - Also, special (symbolic, vendor, ...) information may be present and should be removed.
- The reverse functionality is to make a layout cell from a selected set of shapes: Edit → Hierarchy→ Make Cell

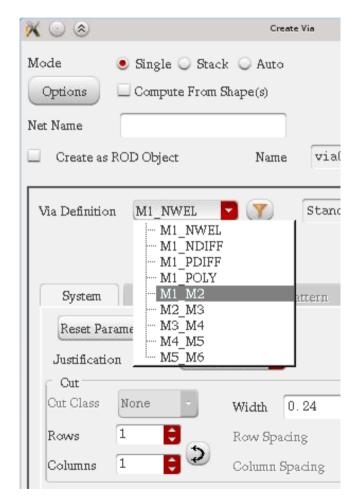




Adding Vias and Contacts

- Vias are connections between adjacent metal layers
- Contacts go to active devices (M1 Poly or M1 Implant)
- Press 'o' to add a via
 - Select the correct layer pair









Zooming ...

■ show everything: 'f' (fit)

scroll: arrow keys

zoom in: ctrl-z or]

zoom out: shift-z or [

zoom area: right mouse – drag

pan selection: tab

last view:

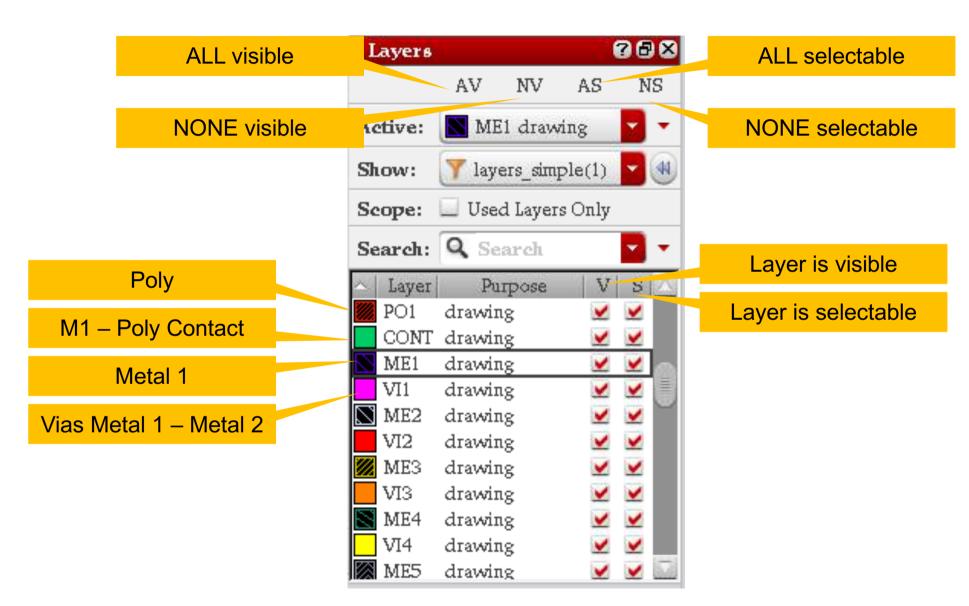
top/bottom/..: ctrl - arrow

■ See menu View → ...





The Routing Layers / The LSW

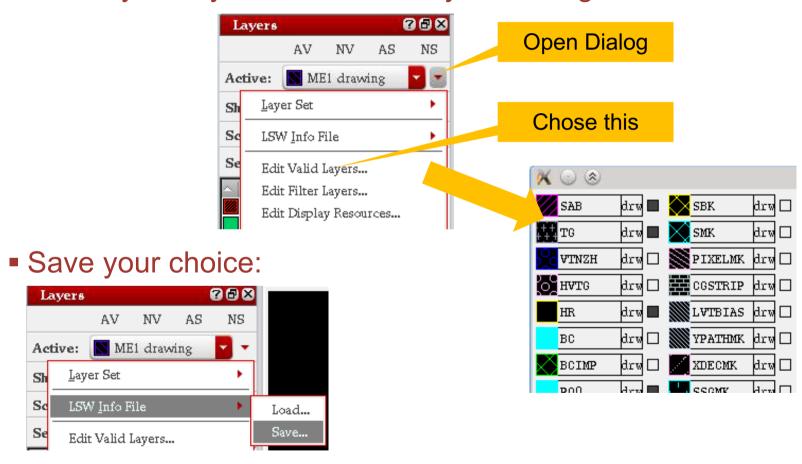






Modifying & Saving a Layer Map

- It is convenient to show only some layers in the LSW
- Chose your layers in the Edit Layers Dialog



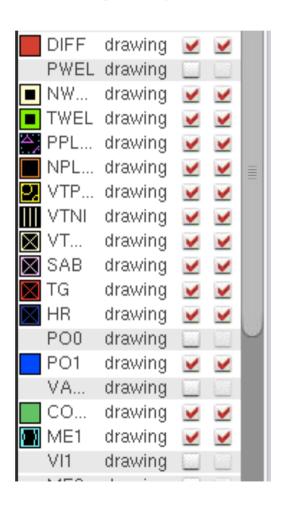
Load a LSW Info file from there

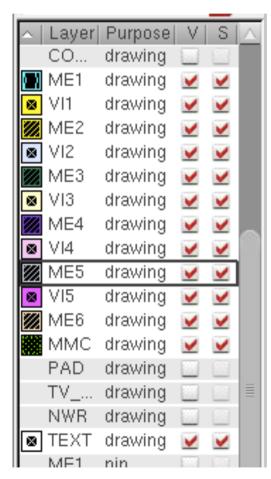




Pre-Defined Layer Sets

- We have pre-defined two layer sets
 - Use keys 8 ('transistors') and 9 ('routing')



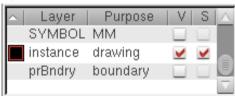




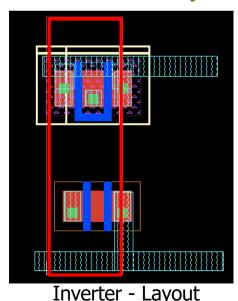


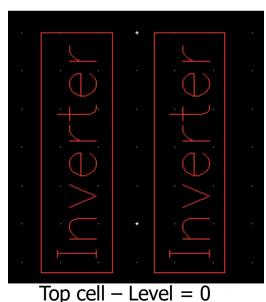
The 'Bounding-Box' and Display Level

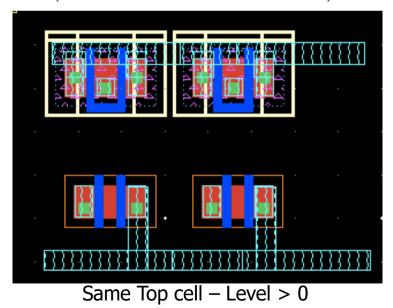
- Similar to the *selection box* of a symbol, a layout can have a 'Bounding Box' which will be displayed in the next hierarchy level (above) when display level is decreased.
 - It is drawn on layer 'instance drawing'
 - You may need to turn the layer on (see prev.)



- If you instantiate the cell (layout):
 - you see only the bounding box if display level = 0 (Ctrl-F)
 - you see 'into' the cell for level > 0 (Shift-F sets level to 20)





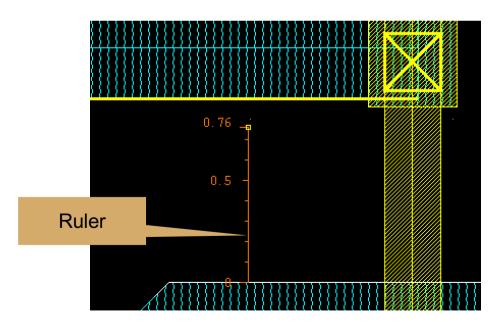


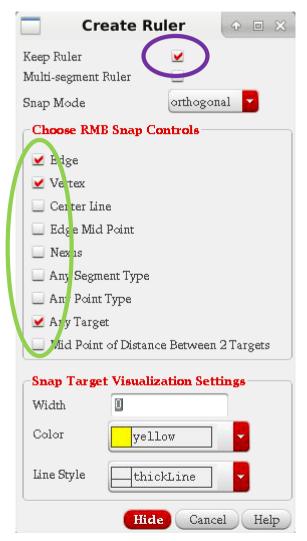




The Ruler: Measuring Distances

- To measure, you can create a 'ruler' (k)
- F3 brings up the usual options form.
 I usually disable all 'Snap' entries.
- When selected, the rulers are kept (and stored for later!)
- All rulers in a view can be deleted with shift-K







EXERCISE





Warmup

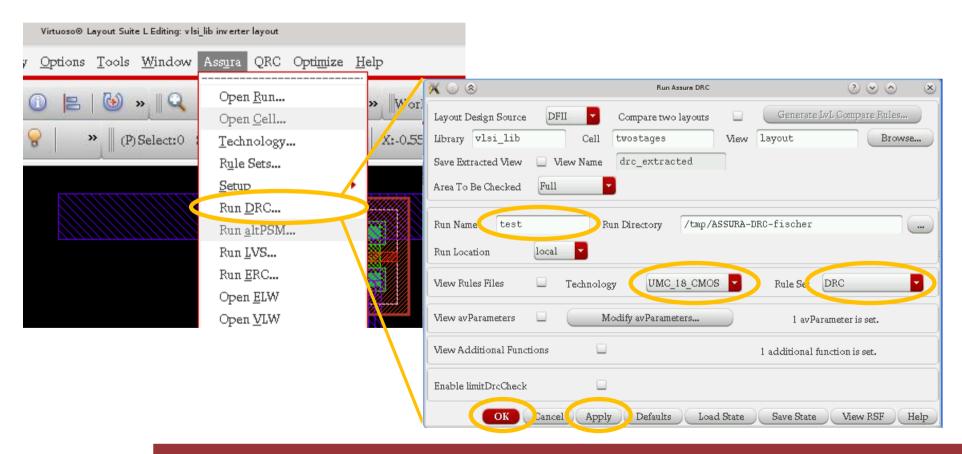
- Play around with the layout editor:
 - Get a PMOS and an NMOS (N_18_MM)
 - Turn on and off layers
 - Draw some metal traces, use Rectangles and Paths
 - Shift things around
 - Modify the paths
 - Get some contacts





Run a DRC for your Layout Tests

- Select from the top menu Assura → Run DRC…
 - Make sure Rule Set DRC is selected
 - Make sure you have set a run name
 - OK closes the window, APPLY keeps it







Inverter and NAND3

- Produce the layout of an inverter
 - Have the PMOS 3 times as wide as the NMOS
 - Put the PMOS at the top, the NMOS at the bottom
 - Put the input on the left side on ME1, the output right on ME2
 - Run power / ground horizontally at top/bottom
 - Connect also the NWELL and the substrate
- Try the layout of a NAND3
 - Try to make the inverter and the layout the same 'height' so that the power connects automatically when placing two cells side-by-side (see next slide)





Layouts

- Do the layout such that multiple gates can be easily placed side by side.
 - Power/ground should run horizontal at bottom and top
 - Find good distances of power traces, wells, ...

